WEST Search History

Hide Items Restore Clear Cancel

DATE: Tuesday, February 22, 2005

Hide?	Set Name	Query	Hit C	ount
	DB=PGPB,	USPT,EPAB,JPAB,DWPI,TDBD; PLUR=Y	ES; OP	=ADJ
	L6	L3 and dripping and slowly		4
	DB = USPT;	PLUR=YES; OP=ADJ		
	L5	L3 and dripping		18
	L4	L3 and slawly		0
	L3	L2 and lifting		730
	L2	wafer and cleaning and removing		10782
I	L1	wafer and cleaning and slowly		2057

END OF SEARCH HISTORY

Hit List

Clear Generale Collection Print Fwd Refs Bkwd Refs
Generate OACS

Search Results - Record(s) 11 through 18 of 18 returned.

11. Document ID: US 6070284 A

L5: Entry 11 of 18

File: USPT

Jun 6, 2000

US-PAT-NO: 6070284

DOCUMENT-IDENTIFIER: US 6070284 A

TITLE: Wafer cleaning method and system

DATE-ISSUED: June 6, 2000

INVENTOR-INFORMATION:

NAME	CITY	STATE	ZIP CODE	COUNTRY
Garcia; Alejandro	Union City	CA		
Krick; Brent	Mountain View	CA		
Nichtawitz; Anthony	Lima			PE .
Nordeen; Daniel	Boulder Creek	CA		
Oen; Josh	Fremont	. CA		
Smith; Kenneth	Cupertino	CA		
Suro; Vincent	Sunnyvale	CA		
Wolf; Daniel	San Jose	CA		

US-CL-CURRENT: <u>15/102</u>; <u>15/77</u>, <u>15/88.3</u>

ABSTRACT:

A <u>wafer cleaning</u> apparatus provides two opposed brushes for brushing a vertically disposed <u>wafer</u> in a tank which can contain a process liquid. A pressure controller adaptively controls the pressure exerted by the brushes on the <u>wafer</u> to compensate for brush wear. Rim driving wheels engage the <u>wafer</u> periphery with a porous jacket coupled to a fluid delivery system, thereby simultaneously rotating and <u>cleaning</u> the periphery of the <u>wafer</u>. The apparatus includes a fluid delivery system for separately and independently delivering a plurality of constituents of a <u>cleaning</u> solution to the brushes, thereby ensuring that a freshly mixed <u>cleaning</u> solution reaches the <u>wafer</u>. The tank can be filled with a process liquid through which megasonic waves provided by a transducer can propagate and impinge upon the <u>wafer</u> thereby enhancing the <u>cleaning</u> of the wafer or the brushes.

33 Claims, 10 Drawing figures Exemplary Claim Number: 33 Number of Drawing Sheets: 9

Full Title Citation Front Review Classification Date Reference Claims KMC Draw De

12. Document ID: US 5974680 A

L5: Entry 12 of 18

File: USPT

Nov 2, 1999

US-PAT-NO: 5974680

DOCUMENT-IDENTIFIER: US 5974680 A

** See image for Certificate of Correction **

TITLE: Apparatus for use in cleaning wafers

DATE-ISSUED: November 2, 1999

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY

Anderson; Gary L. St. Ann MO Wilson; Keith El Cerrito CA

US-CL-CURRENT: 34/58; 134/902

ABSTRACT:

A semiconductor <u>wafer</u> scrubbing and drying apparatus is capable processing <u>wafers</u> in a vertical orientation from start to finish. The apparatus moves the <u>wafers</u> in a generally vertical direction from an entry station of the apparatus to a dryer of the apparatus. The <u>wafers</u> enter the apparatus in a cassette and exit in another cassette in the same order as they were in the entry cassette to preserve individual <u>wafer</u> identity. The apparatus is constructed so that the compartment in which the <u>wafers</u> are handled is isolated and the components handling the <u>wafers</u> in that compartment are made of a fluorinated plastic. The actuators driving the motion of the <u>wafer</u> handling components are located in another compartment. A rinsing device in the <u>wafer</u> handling compartment is activated and deactivate for rinsing one of the <u>wafers</u> without the use of valves in the rinse line.

24 Claims, 19 Drawing figures Exemplary Claim Number: 1 Number of Drawing Sheets: 18

Full	Title	Front	Classification	Date	Reference		Claims	KWIC	Drawn De
						July de			

13. Document ID: US 5927085 A

L5: Entry 13 of 18

File: USPT Jul 27, 1999

US-PAT-NO: 5927085

DOCUMENT-IDENTIFIER: US 5927085 A

TITLE: Commercially viable counter-top beverage dispenser with passive thermal

insulation

DATE-ISSUED: July 27, 1999

May 11, 1999

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY

Waldman; Joseph Bayport NY 11705

US-CL-CURRENT: 62/129; 215/395, 220/23.89, 220/592.17, 62/457.4

ABSTRACT:

A beverage carton dispenser for self-service coffee distribution is provided with passive thermal insulation, a locking means to prevent undesirable beverage-carton slip-out during times when a user employs a steep pouring angle. A vent aperture is provided to relieve inner-air pressure when a milk carton is being installed or removed. A pour handle and re-useable refrigerant gel are also provided. The device is simple, inexpensive and solves the problem of providing a commercially viable counter-top milk dispenser which keeps milk cold in a room-temperature environment without the use of open ice with <u>dripping</u> and puddling water and without active refrigeration requiring an energy input. The presence of the pour handle makes dispensing the beverage easier, safer, and more convenient and provides the user with greater control over pouring the beverage from the container.

23 Claims, 8 Drawing figures Exemplary Claim Number: 1 Number of Drawing Sheets: 4

Fuil T	itie	Citation	Fiont	Review	Classification	Date	Reference		Claims	KWIC	Draw, D
	**********						***************************************	 *************************	************	************	***************************************

File: USPT

•

L5: Entry 14 of 18

US-PAT-NO: 5902402

DOCUMENT-IDENTIFIER: US 5902402 A

TITLE: Device for chemical wet treatment

DATE-ISSUED: May 11, 1999

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY
Durst; Johann Pliezhausen DE
Sigel; Holger Pliezhausen DE
Schulz; Werner Aalen DE

ABSTRACT:

A device for chemical wet treatment of substrates has a tank containing a treatment fluid for treating the substrates. At least one substrate carrier for supporting the substrates within the tank is provided. At least one substrate $\underline{\text{lifting}}$ device for $\underline{\text{lifting}}$ the substrates off the substrate carrier is provided. A $\underline{\text{lifting}}$ apparatus for $\underline{\text{lifting}}$ and lowering the substrate carrier is positioned in the tank.

The <u>lifting</u> apparatus has a first transport carriage connected to the substrate <u>lifting</u> device and a second transport carriage connected to a holder of the substrate carrier. The first and second transport carriages are connected to one another by a jointed connection.

19 Claims, 16 Drawing figures Exemplary Claim Number: 1 Number of Drawing Sheets: 12

15. Document ID: US 5868865 A

L5: Entry 15 of 18

File: USPT

Feb 9, 1999

US-PAT-NO: 5868865

DOCUMENT-IDENTIFIER: US 5868865 A

TITLE: Apparatus and method for washing treatment

DATE-ISSUED: February 9, 1999

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY

Akimoto; Masami Kumamoto JP

US-CL-CURRENT: <u>134/33</u>; <u>134/3</u>, <u>134/32</u>, <u>134/61</u>

ABSTRACT:

Disclosed is an apparatus for washing treatment which comprises a washing solution supply source filled with a washing solution required for chemical washing of a wafer, a spin chuck for rotatably holding a wafer to be treated, a nozzle communicating with the washing solution supply source, for supplying a washing solution from the washing solution supply source onto the wafer held on the spin chuck, temperature controlling device for controlling the temperature of the washing solution to be supplied to the wafer from the nozzle, and a temperature controlled cover closely provided so as to cover the wafer held on the spin chuck, for preventing a substantial temperature variation of the washing solution present on the wafer.

17 Claims, 17 Drawing figures Exemplary Claim Number: 1 Number of Drawing Sheets: 9

-	 							12.14 14.			
Full	Title	Citation	Front	Review	Classification	Date	Reference		Claims	KWIC	Draw, Da

16. Document ID: US 5679055 A

L5: Entry 16 of 18

File: USPT

Oct 21, 1997

US-PAT-NO: 5679055

DOCUMENT-IDENTIFIER: US 5679055 A

TITLE: Automated wafer lapping system

DATE-ISSUED: October 21, 1997

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY

Greene; George W. Burlington MA
Albrecht; Peter D. Spartanburg SC
Strittmatter; Kenneth D. Mauldin SC
Hidalgo; Rafael Greenville SC

US-CL-CURRENT: <u>451/10</u>; <u>451/285</u>, <u>451/286</u>, <u>451/287</u>, <u>451/288</u>, <u>451/289</u>, <u>451/41</u>

ABSTRACT:

An automated <u>wafer</u> lapping system including a robot which loads <u>wafers</u> from a cassette into a <u>wafer</u> carrier on a lapping machine one at a time and one after another. The robot is capable of delivering lapped <u>wafers</u> to a thickness gauging device for measuring the <u>wafer</u> thickness and recalibrating the lapping machine between each run. Openings in the <u>wafer</u> carriers for receiving <u>wafers</u> are sized closely to the <u>wafer</u> for minimal relative motion between the <u>wafer</u> and carrier. A centering jig and search program for the robot facilitate fast location of the <u>wafers</u> in the openings. The lapping system also inspects <u>wafers</u> for defects and sorts them accordingly after lapping.

36 Claims, 18 Drawing figures Exemplary Claim Number: 36 Number of Drawing Sheets: 12

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	Draw De

17. Document ID: US 5655954 A

L5: Entry 17 of 18

File: USPT

Aug 12, 1997

US-PAT-NO: 5655954

DOCUMENT-IDENTIFIER: US 5655954 A

TITLE: Polishing apparatus

DATE-ISSUED: August 12, 1997

INVENTOR-INFORMATION:

NAME	CITY	STATE	ZIP CODE	COUNTRY
Oishi; Toshio	Numazu			JP
Shin; Shoichi	Tagata-gun			JP
Tsunada; Masafumi	Numazu			JP
Ishida; Masahiro	Yokohama			JР

Mase; Yasukazu

Yokohama

JP

US-CL-CURRENT: 451/67; 134/62, 451/287, 451/288, 451/289, 451/66

ABSTRACT:

Provided is a polishing apparatus which comprises a polishing mechanism for polishing a <u>wafer</u> taken out from a cassette, an attaching-detaching device for attaching to and detaching the <u>wafer</u> from the polishing mechanism, a device for <u>cleaning</u> the polished <u>wafer</u>, and a transportation device for transporting the <u>wafer</u> between the cassette, polishing mechanism, attaching-detaching device, and <u>cleaning</u> device. These devices are arranged individually in compartments. A working chamber is divided into a plurality of compartments by means of partitioning devices. A device for polishing a workpiece is set in one of the compartments. The apparatus is also provided with communication devices for internally connecting the adjacent compartments which are divided by the partitioning devices. The apparatus may further comprise devices for individually controlling the respective internal pressures of the compartments or a device for generating an air flow in the form of a laminar flow in each of the compartments.

21 Claims, 8 Drawing figures Exemplary Claim Number: 1 Number of Drawing Sheets: 8

Full	Title	Citation	Front	Review	Classification	Date	Reference		Claims	KOMC	Draini
ប់ដ	Title	Citation	Front	Review	- Classification	Date	Reference	4	Claims		OMC

18. Document ID: US 5437733 A

L5: Entry 18 of 18

File: USPT

Aug 1, 1995

US-PAT-NO: 5437733

DOCUMENT-IDENTIFIER: US 5437733 A

TITLE: Method and apparatus for treating a substrate

DATE-ISSUED: August 1, 1995

INVENTOR-INFORMATION:

NAME CITY STATE ZIP CODE COUNTRY

Okumura; Katsuya Yokohama Jp

US-CL-CURRENT: <u>134/34</u>; <u>134/117</u>, <u>134/122R</u>, <u>134/2</u>, <u>134/48</u>, <u>204/194</u>, <u>205/148</u>, <u>205/157</u>, <u>205/172</u>, <u>205/88</u>, <u>205/96</u>, <u>216/23</u>, <u>216/99</u>, <u>430/434</u>, <u>438/747</u>

ABSTRACT:

A plane of a treatment liquid holder having a number of through holes faces a treatment surface of a substrate. A treatment liquid is held between the treatment surface and the liquid holder by utilizing a surface tension of the treatment liquid. Since the treatment liquid is applied only to the treatment surface, an extremely small amount of treatment liquid suffices for the treatment. In addition, since a fresh treatment liquid can be used in every treatment, cross-contamination is suppressed and the treatment can be performed with safety at a low cost.

31 Claims, 20 Drawing figures Exemplary Claim Number: 1,14 Number of Drawing Sheets: 7

Full Title Citation Front Review Classification Date Refere	ence Claims RMC I
lear Generate Collection Print Fwd Re	efs Bkwd Refs Generate OAC
Term	Documents
DRIPPING	16565
DRIPPINGS	1596
(DRIPPING AND 3).USPT.	18
(L3 AND DRIPPING).USPT.	18

Display Format: REV Change Format

Previous Page Next Page Go to Doc#